# Chapter 8

#### NOBLE GASES

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### 8.1 THE ELEMENTS

The structural properties of liquid and crystalline argon have been investigated using a molecular-mechanical model comprising 108 Lennard-Jones particles. Calorimetric studies of liquid mixtures of xenon with  $\mathrm{HC1}^2$  and  $\mathrm{N_2O}^3$  have been carried out by Staveley et al: the enthalpy of mixing with liquid HCl could be satisfactorily reproduced using perturbation theory; on the other hand with liquid  $\mathrm{N_2O}$  a positive azeotrope formation takes place. The dixenon cation,  $\mathrm{Xe_2}^+$ , has been reported previously; Stern and Henderson have shown that it is formed reversibly according to equation (1).

$$3Xe + XeF^{+}Sb_{2}F_{11}^{-} + 2SbF_{5} = 2Xe_{2}^{+}Sb_{2}F_{11}^{-}$$
 ...(1)

The concentration of  ${\rm Xe_2}^{2+}$  in this system was shown to be proportional to the  $^{3/}{\rm 2}$  power (approximately) of both the xenon pressure and of the  ${\rm XeFSb_2F_{11}}$  concentration, as well as the first power of the  ${\rm SbF_5}$  concentration. The authors infer that the  ${\rm Xe_2}^+$  cation is strongly bound in a complex with excess oxidant.

## 8.2 KRYPTON(II) AND XENON(II)

The 1:1 adduct between  ${\rm KrF}_2$  and  ${\rm BiF}_5$ , which is as stable at room temperature as the  ${\rm SbF}_5$  analogue, has been investigated at low temperature by Raman spectroscopy. Three adducts of  ${\rm XeF}_2$  and  ${\rm BiF}_5$ ,

2:1, 1:1 and 1:2, were also prepared and investigated similarly.  $^5$  The results are of interest in connection with the relative amounts of covalent character in these compounds compared with the SbF $_5$  analogues: in all instances it was found that the BiF $_5$  compounds are more covalent.

The reaction of norbornene with  $XeF_2$  in  $CH_2Cl_2$  has been used as a mechanistic probe to elucidate the effect of catalyst and temperature (-61° to 25°C) on the liquid phase fluorination. Up to seven products were obtained and the catalysts (HF, HF-py,  $BF_3$ ,  $BF_3$ - $Et_2O$ , and  $C_6F_5SH$ ) had a marked effect on the reaction pathway : an analogous study of the fluorination of norbornadiene demonstrated that catalyst and temperature have less effect in this Xenon(II) fluoride converts 1,3-diketones to monoand di-fluoro products when the reaction is carried out in the presence of a mixture of the BF, complex of (cross-linked) polystyrene-4-vinylpyridine resin and of the uncomplexed resin. 7 The reaction of enol acetates with XeF, in the presence of anhydrous HF gave  $\alpha$ -fluoroketones. One of the three possible L-3,4-dihydroxyfluorophenylalanines was found after workup following fluorination of L-3-methoxy-4-hydroxyphenylalanine by XeF<sub>2</sub> in CH<sub>2</sub>Cl<sub>2</sub>: 8 the 6-fluoro compound was isolated in 25% yield.

High rates of surface etching of Ge and Si single crystals by gaseous  $XeF_2$  have been reported by Baklanov et al. <sup>9</sup> The rate of attack does not depend upon either the crystallographic orientation of the crystal surface (over the temperature range  $5^{\circ}-90^{\circ}$ C) or the vapour pressure (5 x  $10^{-2}$  - 1.4 torr) of  $XeF_2$  used.

Holloway and Schrobilgen  $^{10}$  have presented  $^{19}$ F and  $^{129}$ Xe n.m.r. evidence for the structures of the adducts formed between XeF<sub>2</sub> and nMOF<sub>4</sub>, M=Mo or W, n=1, 2, 3 and 4. Interestingly some of these adducts contain XeF...M bridges which are non-labile on the n.m.r. time scale at low temperatures in BrF<sub>5</sub> or SO<sub>2</sub>ClF solutions: these complexes undergo solvolysis in HSO<sub>3</sub>F at  $^{-80}$ C, according to equations (2) and (3), on the basis of n.m.r. studies. A group of

$$FXeFMOF_4 + HSO_3F \longrightarrow F-Xe-OS(O)(F)O-MF_4O + HF$$
 ...(2)

$$FXeOS(O)(F)OMF_4O \iff FXeOSO_2F + MOF_4$$
 ...(3)

adducts  $XeF_2.mWOF_4$ , m=2 or 3, were found to be partially iomerised in  $SO_2ClF$ , e.g. to the 0-bridged compound ( $\underline{1}$ ).

$$FXe-O-WF_4-F-W(O)F_3-F-WF_4O$$
(1)

Jacob has shown that  $(F_3Si)_2O$  is slowly oxidised by  $KrF_2$  and  $XeF_2$ ; reaction (4) is complete in 8h or less at  $25^OC$  (Ng=Kr or Xe).

$$NgF_2 + (SiF_3)_2O \longrightarrow Ng + \frac{1}{2}O_2 + 2SiF_4$$
 ...(4)

### 8.3 XENON(IV)

Adducts with 1 or  ${}^2{\rm BiF}_5$  and  ${}^{\rm XeF}_4$  have been prepared and their low-temperature Raman spectra discussed by Gillespie at al.  ${}^5$  Xenon(IV) fluoride reacts slowly with  $({}^{\rm SiF}_3)_2{}^{\rm O}$ , equation (5).  ${}^{11}$ 

$$xeF_4 + 2(siF_3)_2O \xrightarrow{ca.1d} xe + O_2 + 4siF_4$$
 ...(5)

### 8.4 XENON(VI)

The hexafluoride can be converted conveniently to  ${\rm XeOF}_4$  in the gas-phase reaction (6). This reaction is more controllable

$$xeF_6 + (SiF_3)_2O \longrightarrow xeOF_4 + 2SiF_4$$
 ...(6)

than other sources of oxygen, such as  ${\rm H_2O}$  or  ${\rm SiO_2/HF}$ . The reaction with excess  ${\rm (SiF_3)_2O}$  requires several days and leads to total reduction of  ${\rm XeOF_4}$  to Xe and oxygen. 11

Two new oxofluoroanions of xenon(VI) have been synthesised and characterised by Schrobilgen et al.  $^{12}$  in the course of a study of the reactions between CsF and excess liquid XeOF $_4$ . The product of the room temperature reaction loses XeOF $_4$  at  $^{\rm OC}$ C to yield CsF.3XeOF $_4$ . The 1:1 adduct could be prepared from this by the loss of 2XeOF $_4$  at room temperature. The Raman spectra of XeOF $_5$  ion is consistent with C $_{\rm S}$  symmetry around Xe so that the lone pair is presumably stereochemically active. The structure proposed for the anion in the 1:3 adduct, (2), has three equivalent XeOF $_4$  units bonded to the fluoride ion.

The first example of the fluorination of 1,3-diketones to the 2-fluoroproduct has been described by Yemul and Kagan. They used the graphite-XeF $_6$  intercalation compound,  $C_{19}^{\rm XeF}_6$ , as the fluorinating agent: typically the reaction takes place at room temperature for 24h under which conditions monoketones do not react.

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